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In-liquid plasma: a novel tool in the fabrication of nanomaterials and in the treatment of wastewaters

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Attempts to generate plasma in liquids have been successful and various devices have been proposed. Many reports have described the optimal conditions needed to generate plasma, and mechanisms have been inferred, together with the composition of the plasma. Elucidation of a stable method (and mechanism) to generate plasma in liquids has led to various active investigations into applications of this new energy source. This review article describes the generator and the generation mechanism of in-liquid plasma, and pays attention to the evolving technology. The characteristics of submerged plasma are summarized and examples of nanomaterials syntheses and wastewater treatment are given, both of which have attracted significant attention. Extreme reaction fields can be produced conveniently using electrical power even without the use of chemical substances and high-temperature high-pressure vessels. Chemical reactions can be carried out and environmental remediation processes achieved with high efficiency and operability with the use of in-liquid plasma. Suggestions for introducing in-liquid plasma to chemical processes are discussed.

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Introduction 1

1.1 In-liquid plasma: a novel energy source for chemical reactions

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Many chemists think it is strange that as much as or more than

99% of the substances present in the Universe exist as plasma, whereas the typical gas, solid and liquid states of matter tend to be rather rare in that environment. Compared to the vast scale of the Universe, chemists manufacture products in these states



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(gas, solid, liquid) with very limited materials. Human beings have used plasmas (e.g., the sun and fire) as energy sources for millennia. These classical energy sources have been used in early chemical syntheses and chemical analyses, even though they are difficult to control in the manufacturing process. Accordingly, electrically powered heaters and steam have been used in carrying out chemical reactions. More recently, microwave chemistry has developed significantly in the use of microwaves as the energy source.1 After World War II, the science behind changing substances artificially into plasma and then using this energy source in chemical reactions has been explored actively. However, combinations of plasma and chemical reactions have been limited to solid-phase reactions. Since ordinary plasma mimics a gas, its utilization in the liquid phase has only been possible in irradiating the liquid surface of a sample. Even with strong stirring, the effect of plasma on a liquid sample is not so pronounced. Nonetheless, chemists have considered using plasma as the energy source to activate chemical reactions, even though its use is difficult from the productivity viewpoint.

Recent years have also witnessed the successful generation of stable plasma in solution (referred to as in-liquid plasma); its application in various fields is currently being investigated. Use of in-liquid plasma has attracted significant attention as being a hot research topic. The state of new substances generated in liquids is expected to be a new tool in solution chemistry fostered by a combination of innovative ideas and the promise of novel materials synthesis. For instance, in-liquid plasma could be applied to fuel (hydrogen) recovery from a methane hydrate layer existing in Japanese waters; the method used is detailed in Fig. 1.² It involves irradiating a methane hydrate layer with in-liquid plasma to achieve dehydrogenation reaction

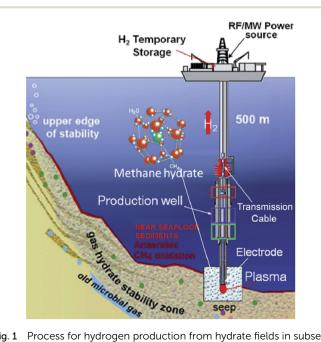


Fig. 1 Process for hydrogen production from hydrate fields in subsea sites using the plasma from the in-liquid method. Reproduced from Rahim and coworkers.² Copyright 2015 by Elsevier.

and recover hydrogen energy from bubbles deep in oceanic waters. In the existing method, the methane hydrate is recovered using a pump; however, it is possible to recover the required amount of hydrogen from the seabed without the use of pumps. Depending on conditions, in-liquid plasma can drive various chemical processes.

1.2 Plasma

Although plasma is an emerging technology in many fields of application, the history of plasma technology goes as far back as the 18th century. Georg Christoph Lichtenberg (1742–1799), a professor of mathematics in Göttingen (Germany), produced brush discharges by spreading fern spores between two electrodes.³

Michael Faraday (1791-1867), discoverer of electromagnetism in 1821, was the first to provide an explanation for Lichtenberg's observations. His countryman, Sir William Crookes (1832-1919), later discovered the fourth state of matter as radiating matter in discharge tubes,4 which he correctly assumed to consist of electrically charged gas molecules in the tubes: de facto, plasma was born. He later defined it in his lecture titled "On Radiant Matter" delivered before the British Association for the Advancement of Science, on 22 August 1879 at Sheffield (D. Appleton, The Popular Science Monthly, 1880, Volume 16, pp 157–167). Crookes discovery was followed nearly two decades later (1897) by Sir Joseph John Thomson's (1856-1940) postulation that atoms consist of positively charged electrons that possess a mass.5 This was also confirmed by the German chemist Eugen Goldstein, who discovered that the socalled canal rays consisted of positively charged particles with missing electrons (H⁺ ions from hydrogen gas). Thus, plasma had been identified as a mixture of electrons and ions. The term plasma was finally defined by the American chemist Irving Langmuir (1881-1957) who in 1923 observed specific oscillations in an ionized gas that he referred to as plasma oscillations generated from an inhomogeneous charge distribution and to the natural tendency of the charge to redistribute uniformly inside the plasma.6 The first comprehensive published report on gas discharges was by the German physicist Johannes Stark (Die Elektrizität in Gasen), then Director of the Institute of Physics of the University of Greifswald. Stark was awarded the 1919 Nobel Prize for the discovery of the Doppler Effect in canal rays and for the splitting of the spectral lines in electric fields (the Stark Effect). At the end of 1918, Stark invited Rudolf Seeliger to the University of Greifswald who remained until 1955. Seeliger is one of the pioneers of modern plasma and gasdischarge physics. The fundamental physical properties of plasma were clarified in the first half of the 20th century by Seeliger and others, which led to rapid advances in the engineering applications of plasmas,⁷ as exemplified by the inventions of the mercury discharge lamp (Cooper Hewitt light: 1902), the mercury arc lamp (1905), and the high-pressure mercury lamp (1906) among others.

Coupling theory and technological innovations in plasma applications also advanced noticeably. In the second half of the 20th century, plasmas were used increasingly for a variety of purposes, such as in neon tubes (vacuum) and in etching processes (hot). Technological progress in the mid-1990s also led plasmas to be generated non-thermally under atmospheric pressure, which opened loads of new possibilities since expensive and complex vacuum systems were no longer needed; processes could now be run continuously without putting stress on materials being treated. As a result, plasma-induced processes could then be applied in, for instance, the medical sector for the gentle sterilization of medical equipment and catheters. In 1996, Laroussi⁸ was one of the first to describe a novel sterilization method that used uniform glow discharge plasma generated at atmospheric pressure. He examined the inactivation of *Pseudomonas fluorescens* bacteria in yeast extract in a polypeptone glucose solution.

Starting with a handful of publications in the mid-1990s, the number of publications that dealt with applications of plasmas increased rapidly at the turn of the 21st century. Indeed, the total number of publications dealing with cold plasma has increased significantly in the past 20 years, attesting to the importance of this emerging technology. As we speak, various engineering application advances are being made. This indispensable technology has developed and currently used extensively in metal welding, in surface treatments, in the processing of materials and electronic components, in the fabrication of nanomaterials, and in wastewater treatment (among others).⁶

Plasma is classified as (i) high-temperature plasma (thermal equilibrium plasma), and (ii) as low-temperature plasma (nonthermal equilibrium plasma). Thermal equilibrium plasma is plasma generated by applying electrical power for a long time under conditions that the gas pressure is 5 kPa or more, and that the electron and gas temperatures are nearly equal. Since the ionization energy of atoms and molecules necessitates several eV or more (tens of thousands of degrees Celsius), some of the electrons and ions become high-energy particles. In general, the materials temperature in thermal equilibrium plasma reaches as much as several thousand degrees Celsius or more; this plasma is casually used as a heat source and light source for welding and lamps. By comparison, the electron temperature is higher than the gas temperature in non-thermal equilibrium plasma. For example, to convert a gas molecule into non-thermal equilibrium plasma, heat transfer to ions and molecules can be restricted by setting gas molecules to a reduced pressure state and by lowering the frequency of collision of electrons with ions or molecules. A characteristic of non-thermal equilibrium plasma is that its gas temperature is low and electrons are in a high-energy state, and as such it is used in the manufacturing of semiconductors and films through chemical reactions. Since non-thermal equilibrium plasma must maintain reduced pressure conditions, facilities such as a vacuum chamber and a vacuum evacuation device are required, even if plasma were generated by a short pulse discharge under atmospheric pressure conditions. This is often referred to as atmospheric pressure non-thermal equilibrium plasma because it has different properties from the plasma in vacuum.

2. In-liquid plasma

2.1 Why plasma can be generated in a liquid (and in a solid)

Since plasma is a state of matter generated by a destabilizing gas, one must ask whether plasma can also form in solids and liquids. Some people are still sceptical about this.

2.1.1 Solid plasma. Regardless of such scepticism, an electron in a metal (solid) contains free electrons that can move around a lattice point; collectively, these are oscillating electrons. When an external electric field is applied to a free electron, it acts as if it were an electron in gas plasma. Although the plasma defined by Langmuir is referred to as gas plasma,⁹ when applied to a solid it can be regarded as a solid plasma even for a solid (metals, semiconductors) that possesses free electrons.¹⁰ The collective oscillation of these free charges (mainly electrons) is known as plasma oscillation; quantizing this oscillation leads to formation of a Plasmon. When metallic nanoparticles are irradiated with specific light, a resonant luminescence appears caused by Plasmon absorption; applications of such nanoparticles in paints, in medical treatment, in measurements, and in microfabrication have been reported.¹¹

2.1.2 In-liquid plasma. For years, some techniques have made use of in-liquid plasma to perform electrical discharge machining, welding, and carburizing (and others) in liquids. Yet, only but a few research studies have taken the trouble to explore and exploit in-liquid plasma, so that its use has been rather limited. The report published by Clements in 1987 (ref. 12) on plasma generation by a high-voltage pulse discharge in water (material changed to a plasma state) was a leading research study of the 1980s. Since then, various studies of the physical elucidation of in-liquid plasma have been carried out from many research quarters, which reported that plasma generated in the liquid phase is a phenomenon greatly different from plasma in the gas phase and suggested the use of in-liquid plasma to wastewater treatment as one of several possible applications. Following these reports, researchers worldwide have optimized in-liquid plasmas with regard to such factors as pressure, temperature, density, viscosity, composition, and conductivity13 that have led to an accelerated development of inliquid plasma generators. In addition to gas-phase plasma used in academia, the bases of plasma in the solid phase and in the liquid phase are now also academically established; systematization of plasma in each state of matter is progressing (Fig. 2). Research into practical applications is also on the increase.

There are two key methods of generating in-liquid plasma. The first key method is an underwater streamer discharge that produces linear plasma in the liquid; the dielectric breakdown of the liquid turns into a type of corona discharge considering the classification of general plasma. During the dielectric breakdown of water, micro-bubbles are formed near the electrode by cavitation produced either by a high electric field or by heating from a conductive current; the plasma is generated in the micro-bubble.¹² To generate an underwater streamer discharge, even in an aqueous solution, an electrical power of 50 to 400 kV and a current of 100 A or more are required. Industrially, it is difficult to achieve and maintain a steady-state

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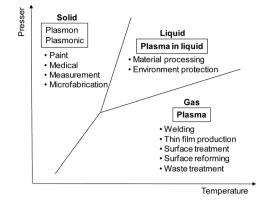


Fig. 2 Relationship between plasma and the three states of matter.

electrical power of this magnitude from the viewpoint of stability and energy saving. Accordingly, many discharges are generated using a pulsed voltage of 1 µs duration or less. An underwater streamer discharge occurs in liquid at a rate of 30 to 100 mm μ s⁻¹ while the liquid is being vaporized at the liquid/air interface.14,15 The occurrence of an underwater streamer discharge in the liquid phase generates ultraviolet rays, shock waves, and localized heat, together with chemically active species formed by the resulting plasma.16 The second key method is to generate bubbles by heating, by shock waves, and by gas introduction (or the like) in the liquid to create in-liquid plasma. Since applying electrical power is not always accompanied by a dielectric breakdown of the liquid, in many cases plasma can still be generated with a power of 10 kW or less as a glow discharge, a corona discharge (streamer discharge), and as an arc discharge.

Except for underwater streamer discharge, this review article will restrict its considerations to all in-liquid plasmas as plasma generated in bubbles contained within the liquid.

2.1.3 Chemical composition of plasma generated in a liquid. When plasma is generated in a liquid by ionizing ionexchanged water, a pale white light is observed (Fig. 3a);¹⁷ the emission spectrum displayed in Fig. 3b is attributed to H_{α} (at λ = 656 nm) and to H_{β} (at 486 nm), and to 'OH radicals (at 316 nm). Therefore, the source of plasma is not due to dissolved air in water, but rather to vaporized water that has turned into plasma. Peaks derived from dissolved nitrogen and oxygen gases at λ = 289 nm (N_{β}) and λ = 778 nm (O*) have also been detected as sharp luminescence.¹⁸

2.2 Methods to generate in-liquid plasma

Fig. 4a shows near surface interactions with plasmas generated outside the liquid.¹⁹ From the cocktail of plasma, such species as radicals, ions, electrons and photons are thought to interact, to differing degrees, with the liquid interface, thereby initiating reactions that cascade well into the liquid phase, possibly *via* biochemical pathways (Fig. 4a). Radicals, ions and photons are often considered, but in attempts to isolate important sources of reactions within liquids, it is also necessary to consider electron interactions directly with the liquid phase (Fig. 4b and

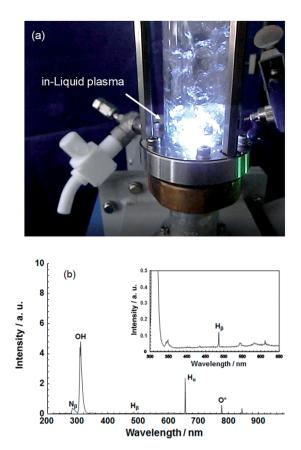


Fig. 3 (a) Photograph illustrating the generation of plasma in liquid using a microwave power supply; (b) spectrum of ultraviolet and visible light emitted by in-liquid plasma generated in ion-exchanged water. Taken from ref. 17. Copyright 2017 by S. Horikoshi.

c); to date, these have received little attention. Accordingly, the focus of this paper will be restricted to phenomena occurring under plasma conditions as illustrated in Fig. 4b and c.

Currently, methods to generate in-liquid plasma can be broadly divided into four categories, and since each possesses

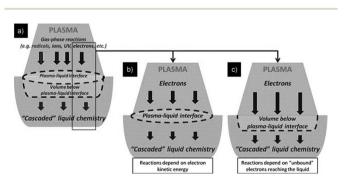


Fig. 4 Schematic diagram of three different types of plasma in-liquid conditions (PiLC): (a) gas-phase species and plasma-radiation-induced liquid reactions at the plasma–liquid interface; (b and c) electrons from the plasma can initiate non-equilibrium reactions in the liquid phase where both electron energy distribution (b) and electron density play an important and distinct role (c). Reproduced from Mariotti *et al.*¹⁹ Copyright 2012 by WILEY-VCH.

its own characteristics, it is necessary to select the appropriate plasma according to purpose and end-use. Considering electrode configurations and energy sources, generated in-liquid plasma can be subdivided as:

(1) Plasma A: direct discharge between two electrodes using an AC (plus) power supply.

(2) Plasma B: contact discharge between an electrode and the surface of the surrounding electrolyte using a DC power supply.

(3) Plasma C: plasma generated with either radio frequency (RF) or microwave (MW) irradiation.

(4) Plasma D: plasma generated using the laser ablation technique.

The schematic of generating Plasma A involves a direct discharge between two electrodes that comes in such forms as solution plasma, discharge plasma in liquid, electric spark discharge, arc discharge, capillary discharge, and streamer discharge (Fig. 5a). Two electrodes of similar size and shape are immersed in the liquid at a short distance. Because of the direct discharge, most liquids containing conductive electrolytes in such media as deionized water, ethanol, and liquid nitrogen can be used. Thus, in-liquid plasma is generated between the two electrodes immersed in the electrolyte solution after passing an electric current through the solution. It is important that the liquid used in this method be conductive.

The schematic of Plasma B is displayed in Fig. 5b. In 1963, Hickling and Ingram reported contact glow discharge electrolysis (CGDE),²⁰ whereby a high-temperature plasma sheath formed between an electrode and the surface of the surrounding electrolyte as a result of a high electric field; this was subsequently accompanied by a glow discharge photoemission. Consider now two electrodes immersed in a conductive electrolyte in which the distance between them is varied from 5 mm to over 100 mm, and the electrode surface area between the anode and cathode is different; one of the electrodes has a smaller surface area than the other. The electrode

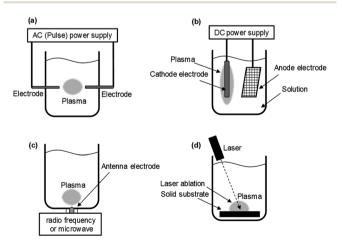


Fig. 5 Images of plasma generation method in a liquid: (a) direct discharge between two electrodes using an AC (plus) power supply; (b) contact discharge between an electrode and the surface of the surrounding electrolyte using a DC power supply; (c) plasma generation with radio frequency (RF) or microwave (MW) irradiation; (d) plasma generation using the laser ablation method.

with the smaller surface area is covered with a thin film of water vapor within which a discharge occurs. In a submerged plasma two-electrode generator that uses a direct current power supply, passing the electric current through the electrolyte liquid produces foam owing to Joule heating; the in-liquid plasma is generated at the cathode side. In such a system, as the conductivity of the liquid changes, the conditions under which the in-liquid plasma is generated also change, so that it is necessary to keep the conductivity at an appropriate level. In most cases, the cathode consists of a metal plate with a large surface area (*e.g.*, a Pt mesh), while the anode is a metal wire. A stable DC power supply is often used, although pulsed DC has also been used.

Techniques for generating in-liquid plasma by irradiating an antenna electrode with radio frequency or microwaves for Plasma C have been utilized in a variety of fields (Fig. 5c). These techniques are effective in generating in-liquid plasma at a lower electrical power. In the plasma generating apparatus, the dielectric constant and the dielectric loss of the liquid are important factors in the generation process. Unlike other techniques, however, it is not necessary to use an electrolyte solution. Radio frequency or microwave generated in-liquid plasma can be maintained in water over a wide range of water conductivity (from 0.2 to 7000 mS m^{-1}). When plasma is generated in a solution using radio frequency or microwaves, a lower pressure is often applied because energy is absorbed by water as it possesses a dielectric constant and dielectric loss. An advantage here is that plasma can be generated even in pure water, and so various application developments can be expected.

Another method for generating plasma in a liquid uses the laser ablation technique (Plasma D; Fig. 5d). The laser irradiates a solid substrate immersed in the liquid causing a plasma ball to be generated on the surface of the solid. This technology is applied in such research as nanoparticle production²¹ and deep-sea mass spectrometry.²²

The various techniques for generating Plasma A–C proposed according to usage conditions, reaction conditions, and operating equipment (among others) have been classified in some detail by Saito and Akiyama²³ who explained the classification based on the corresponding engineering diagram for the Plasma A–C summarized in Fig. 6,^{23–84} 7,^{85–128} and 8.^{129–154}

2.3 Problems and countermeasures in plasma generation

To generate plasma continuously in a liquid necessitates application of a large electrical power as compared to the case of generating plasma in vacuum or under atmospheric pressure, so that the thermal load on the electrode is large. Consequently, studies on electrodes used in plasma generation have been carried out for many years. In-liquid plasmas have been generated using electrodes made with such materials as tungsten, aluminum, copper, molybdenum, stainless steel (SUS 304), and carbon. Plasma generation with electrodes made of carbon, molybdenum, and SUS 304 lasted no more than 5 min.¹⁵⁵ Moreover, continuous (for 10 min) in-liquid plasma generation with aluminum and copper electrodes caused

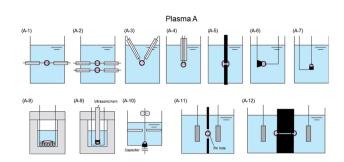


Fig. 6 Typical electrode configuration for Plasma A: (A-1) influence of glow discharge plasma and dielectric barrier discharge;^{24–30} (A-2) dielectric barrier discharge in quartz tube;³¹ (A-3) gliding arc discharge;³² (A-4) gas–liquid interfacial plasma, plasma electrochemistry in ionic liquids, and so forth;^{33–45} (A-5) glow discharge formation over water surface;⁴⁶ (A-6) discharge electrolysis;^{47–64} (A-7) microplasma;^{19,65–75} (A-8) dual plasma electrolysis;⁷⁶ (A-9) plasma in contact with liquids;^{77,78} (A-10) microplasma discharge;⁷⁹ (A-11) glow discharge generated in contact with a flowing liquid cathode;^{80–84} (A-12) AC capillary discharge. Modified with permission from ref. 23. Copyright 2015 by Hindawi.

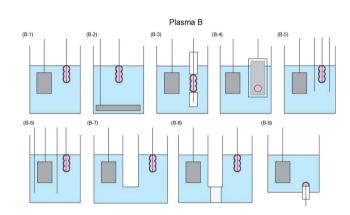


Fig. 7 Typical electrode configuration for Plasma B: (B-1) contact glow discharge;⁸⁵⁻¹⁰⁸ (B-2) electrical discharges,¹⁰⁹⁻¹¹¹ streamer discharge plasma in water;¹¹² (B-3) solution plasma;^{91,93,99,113} electric discharge plasma;¹¹⁴ (B-4) contact glow discharge;^{113,115,116} (B-5) contact glow discharge;¹¹⁷ (B-6) contact glow discharge electrol-ysis;¹¹⁸⁻¹²⁰ (B-7) high-voltage cathodic polarization;¹²¹ (B-8) contact glow discharge electrol-ysis;^{118,120-125} and (B-9) electrical discharge.¹²⁶⁻¹²⁸ Modified with permission from ref. 23. Copyright 2015 by Hindawi.

deterioration of the electrode surface. On the other hand, for electrode material with high melting points (*e.g.*, tungsten, mp = 3422 °C), the electrode could, in principle, withstand long-term use (Fig. 9). Nonetheless, deterioration of the electrode surface can still occur depending on the generation conditions of the in-liquid plasma. Therefore, studies on the mechanism of in-liquid plasma heating of the electrodes and improvement measures are ongoing.

Many of the currently reported in-liquid plasmas produce bubbles within which plasma is generated in the liquid. However, if the bubble generating device were to be connected separately, the physical structure of the plasma generating portion would get rather complicated. To resolve this problem, an ultrasonic wave irradiation device is installed in the vicinity

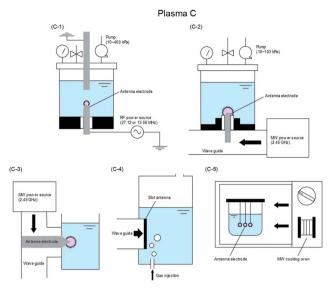


Fig. 8 Typical electrode configuration for Plasma C: (C-1) RF applied in-liquid plasma system under vacuum condition;¹²⁹⁻¹⁴⁰ (C-2) MW applied in-liquid plasma system under vacuum condition;^{134,141-149} (C-3) MW-induced in-liquid plasma system under atmosphere condition;^{550,151} (C-4) slot-excited MW discharge in-liquid plasma system under atmosphere condition;¹⁵² and (C-5) in-liquid plasma generation system with a MW oven.^{153,154} Modified with permission from ref. 23. Copyright 2015 by Hindawi.

of the plasma generating electrode. Even with this method, however, it is not possible to improve the apparatus complexity in the vicinity where plasma is generated. Accordingly, an apparatus has been developed in which the electrode and the ultrasonic homogenizer horn are integrated.

For instance, by sharing the microwave antenna electrode with the ultrasonic homogenizer as an in-liquid plasma apparatus driven by a single microwave power supply, both microwaves and ultrasonic waves can be used to irradiate simultaneously, thereby simplifying the apparatus (Fig. 10).¹⁵⁶ Since the ultrasonic homogenizer can generate fine bubbles in the liquid, they can be produced in the very vicinity where

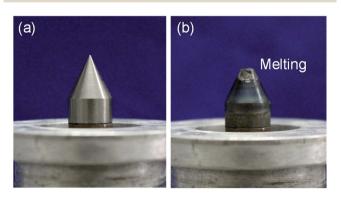


Fig. 9 (a) Photograph of a tungsten pencil-type electrode of an inliquid plasma generator of the microwave type in an unused state; (b) photograph of a tungsten pencil-type electrode after several minutes of generating in-liquid plasma with continuous microwaves. Taken from ref. 17. Copyright 2017 by S. Horikoshi.

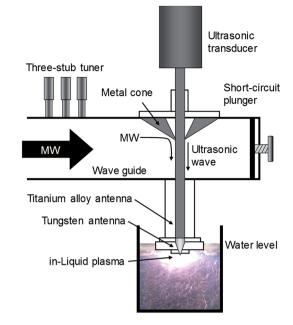


Fig. 10 Schematic diagram of an ultrasonic/microwave simultaneous irradiation type in-liquid plasma generator system. Reproduced from Horikoshi *et al.*¹⁵⁶ Copyright 2017 by Elsevier.

plasma is generated, causing plasma to be generated efficiently in the bubbles. Using the latter method, even if the incident power of the microwaves were reduced by 45% or more, compared to the existing apparatus without ultrasonic waves, in-liquid plasma could still be generated continuously and deterioration of the electrode could be minimized if not suppressed for long periods of use.

In-liquid plasma applications

3.1 Nanomaterials synthesis

3.1.1 Noble metals, alloys and metal-oxide nanoparticles. Two methods have been reported for nanoparticle synthesis using in-liquid plasma. The first method utilizes dissolution of the electrode described in Section 2.3. In the case of in-liquid plasma, dissolution of the electrode surface proceeds by local heating; utilizing this phenomenon provides a method in which nanoparticles are produced by aggregating the electrode metal while evaporating the electrode surface (evaporation method). The second method (reduction method) involves reduction of a metal salt in aqueous media with the in-liquid plasma to synthesize metal nanoparticles. Nanoparticle synthesis by a gasphase plasma reduction method has already been achieved; however, substituting this by a liquid-phase plasma increases the number of molecules of raw materials contained in the system by orders of magnitude. Hence, at laboratory level, for example, a yield of more than 10 g h^{-1} can be obtained. In addition, unlike the nanoparticle synthesis process occurring by gas-phase plasma, aggregation of generated particles can be prevented immediately by adding a particle agglutination inhibitor (or the like) into the solution.

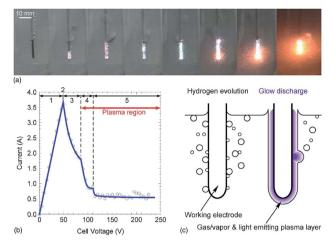


Fig. 11 (a) Photograph of plasma emission during the formation of nanoparticles; (b) relationship between current and voltage; (c) cartoon illustrating the process of nanoparticle generation. Reproduced from Toriyabe *et al.*⁸⁸ Copyright 2007 by the American Institute of Physics.

Dissolution of the electrode method. Studies have been conducted on the evaporation method to form various metallic nanoparticles by placing cathode electrodes of various metals in a potassium carbonate solution, followed by applying a direct current to this solution to evaporate and dissolve the electrodes. Metallic nanoparticles have been formed in solution during the evaporation of Ni, Ti, Ag, and Au nanowire electrodes with inliquid plasma (Fig. 11).⁸⁸ The advantage of this method is that various kinds of nanoparticles can easily be formed in a liquid by simply changing the kind of metal used for the wire electrode. Along similar lines, Saito and coworkers⁹⁴ reported the syntheses of a single crystal tin oxide plate (SnO) and a Sn₆O₄(OH)₄ skeleton using tin wire immersed in an electrolyte solution.

The size and shape of these nanoparticles can be controlled by changing the synthesis conditions (reaction temperature, cooling temperature, dispersant) of generating in-liquid plasma (Fig. 12).94 And even if plasma conditions were changed, the morphology and the nature of nanoparticles could still be controlled (Fig. 13).99 Metal electrodes can be volatilized using wide-area plasma, partial plasma, and partial plasma under high-temperature conditions. Accordingly, it is possible to produce Ti, Fe, Ni, Cu, Zn, Zr, Nb, Mo, Ag, W, Pt, Au, and SUS 316 nanoparticles using in-liquid plasma as the energy source. In addition, alloy nanoparticles of gold and platinum can be made by the simultaneous evaporation of the two electrode materials with in-liquid plasma (Fig. 14).157 Another study reported the evaporation of a platinum electrode with in-liquid plasma to produce platinum nanoparticles (particle size, 2 nm) supported on a highly conductive carbon black support dispersed in water.¹⁵⁸ This Pt/C catalyst was produced with very high efficiency and used as a catalyst in fuel cells.

Reduced reaction with plasma method. Zinc oxide nanoparticles (ZnO NPs) have been produced using in-liquid plasma.⁹⁰ In this case, a Zn wire (the cathode) and a mesh

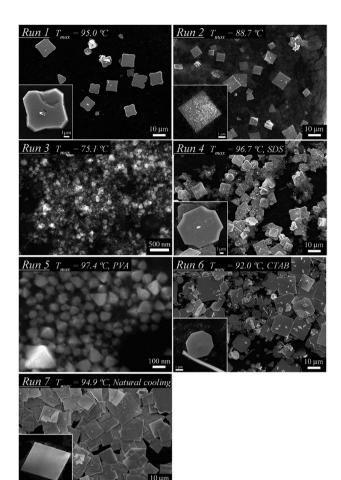


Fig. 12 SEM images of single crystals of a tin oxide SnO plate synthesized by in-liquid plasma under different reaction temperatures, dispersant and cooling conditions. Reproduced from Saito *et al.*⁹⁴ Copyright 2012 by the American Chemical Society.

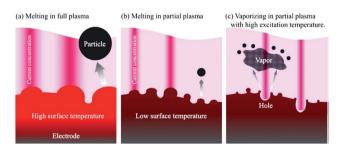


Fig. 13 Images of (a) a wide-area plasma; (b) a partial plasma; and (c) the volatilization of a metal electrode by partial plasma under high temperature conditions. Reproduced from Saito *et al.*⁹⁹ Copyright 2014 by the American Institute of Physics.

made of Pt wire (the anode) were submersed in an aqueous solution of K_2CO_3 . Application of a certain voltage to the solution system generated plasma in the immersed part of the Zn wire. Using medium-power input levels resulted in the formation of flower-like ZnO NPs (Fig. 15a and b),⁹⁰ while applying high-power input levels yielded aggregated ZnO NPs (Fig. 15c);

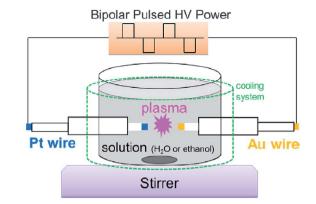


Fig. 14 Image of a synthesis apparatus of a gold/platinum alloy by inliquid plasma using gold and platinum electrodes. Reproduced from Hua and coworkers.¹⁵⁷ Copyright 2013 by Elsevier.

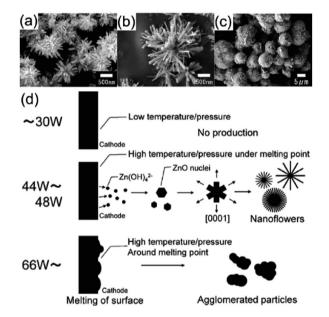


Fig. 15 SEM images of products obtained from in-liquid plasma usage; experimental conditions of K_2CO_3 concentration, and discharge voltage/power are: (a) 1.0 M, 66 V/44 W, (b) 0.5 M, 80 V/48 W, (c) 0.01 M, 200 V/168 W. (d) Schematic processes in the synthesis of ZnO nanoflowers and ZnO aggregates using in-liquid plasma. Modified with permission from ref. 90. Copyright 2011 by Elsevier.

the mechanism of the synthesis is summarized in Fig. 15d. The Zn wire is first oxidized to ZnO on its surface after plasma generation. At low power, the surface temperature of the electrode is below the melting point of zinc and some $Zn(OH)_4^{2-}$ species form around the Zn wire (reaction (1)).

$$ZnO(s) + H_2O + 2OH^- \rightarrow Zn(OH)_4^{2-}$$
(1)

Subsequently, $Zn(OH)_4^{2-}$ migrates to the low-temperature zone and decomposes into ZnO (reaction (2)).

$$Zn(OH)_4^{2-} \rightarrow ZnO(s) + H_2O + 2OH^-$$
(2)

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The ZnO nanoparticles grow preferentially along the [0001] direction 159,160 to form the flower-like ZnO nanoparticles. However, at high power (*i.e.*, at >300 W cm⁻² (ref. 90)), the temperature of the Zn wire reaches its melting point causing rapid evaporation of the Zn wire and the ZnO film resulting in ZnO particle aggregates (Fig. 15c).

Research studies are also being conducted actively on a reduction method to synthesize various nanoparticles. For instance, gold-based bimetallic particles, (*e.g.*, Au–Fe, Au–Ga, Au–In or the like) can be produced using a metal-ion reduction method and a metal nitrate as the precursor from bivalent sp metals, trivalent sp metals, or 3d and 4d metals. A one-step

 Table 1
 Synthesis of noble metals, alloys and metal-oxide nanoparticles using various in-liquid plasma-related methods (see Fig. 6 for the in-liquid plasma methods)

HauCl,Plasma A140HAuCl,Plasma B86AgPlasma B86AgPlasma B88 and 9AgNO,Plasma A180 r183AgNO,Plasma A184 andAgxO,Plasma A186Plasma A186160 r100 r100 r100 r100 r100 r100 r100 r	Nanoparticles produced	Starting materials	In-liquid plasma methods	Ref.
PartialPlasma A1401400NakuCl4Plasma B86AgNakuCl4Plasma B86AgPlasma B88 and 9Plasma B88 and 9AgNO3Plasma A184 andAgNO3Plasma A186Plasma PPlasma A86NiNickel wirePlasma A86CuC3Plasma A188CuC4CuC3Plasma A188CuC3Plasma A18886NiNickel wirePlasma A86CuC4CuC4Plasma A18986CuC4CuC4Plasma A8686SnCuC3Plasma A18986Pl-AuPlasM2Plasma A8686SnTin rodPlasma B8686SnTin rodPlasma B86102Sn-AuPlasma PPlasma B102Ni-CuNi(NO3), 6H:JO, Cu(NO3), 2H:JO, Plasma A192Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-PbAlloy wirePlasma B102Sn-PbAlloy wirePlasma B102Sn	Au	Gold rod or wire	Plasma A	165-169
Handl,Plasma B107-079NatuCi,Plasma B86AgNatuCi,Plasma A180-183Plasma C140, 147Plasma C140, 147AgNO,Plasma A186ParaAgNO,Plasma A186ParaPlasma A186ParaPlasma A186ParaPlasma A186ParaPlasma A187ParaPlasma B96ParaPlasma B86NiH_PFCIa,Plasma B86NiCuC,Plasma A188CuCuC,Plasma A189CuCuC,Plasma A180ShMiroPlasma A180ShMiroPlasma A180 <td></td> <td></td> <td>Plasma B</td> <td>88, 99 and 114</td>			Plasma B	88, 99 and 114
AgNauCi, Bilter rod or wire Bilter rod or wire Plasma APlasma A86AgAgPlasma A84 and 9AgAgNO, Agzeolite Plasma APlasma A184 and 184 an			Plasma C	140
Nacci,Plasma A86AgSilver rod or wirePlasma A80 – 183AgAgPlasma A84 andAgNO_1Plasma A184 andAg2 colitePlasma A184 andAg2 colitePlasma A186PePlasma A186PePlasma A186PePlasma A187Plasma C151151Aga ColitePlasma A86ColitePlasma A86ColitePlasma A86ColiteCologer wirePlasma A88CuCl_Coper wirePlasma A189 andCuCl_Coper wirePlasma A86CuCl_Coper wirePlasma A86CuCl_Coper wirePlasma A88, 89, 9CuCl_Coper wirePlasma A86CuCl_Coper wirePlasma A88, 89, 9CuCl_Coper wirePlasma A88, 89, 9CuCl_Coper wirePlasma A88, 89, 9CuCl_Coper wirePlasma A88, 89, 9ZonCuCl_Plasma A189ZonCuCl_Plasma A189Zon <td< td=""><td></td><td>HAuCl₄</td><td>Plasma A</td><td>170-179</td></td<>		HAuCl₄	Plasma A	170-179
AgSilver rod or wirePlasma A180-183 Plasma B88 and 3 Plasma C180 180, 147 Plasma A181 180, 147AgNO3Plasma A184 and 0Ag-zeolitePlasma A184 186PrPlatinum wirePlasma A187PrPlatinum wirePlasma A187PrPlasma A187186PrPlasma A187186NiNickel wirePlasma A66CuCopper wirePlasma A86CuCopper wirePlasma A189 andCuCopper wirePlasma A189 andCuCopper wirePlasma A189 andCuCopper wirePlasma A189 andCuCopper wirePlasma A189 andCuCuCd2Plasma A189 andCuCuCd2Plasma A189 andCuCuCd2Plasma A189 andCuCuCd2Plasma A189 andCuCuCd2Plasma A180 andCuCuCd2Plasma A180 andCuCuCd2Plasma A180 andCuCuCd2Plasma A191 andPlasma ANa192 and114 andShTin rodPlasma A191 andPlasma AAlloy wirePlasma A192 andSh-PbAlloy wirePlasma B102 andNi-CuAlloy wirePlasma B102 and		-	Plasma B	86
oPlasma B84 and 9AgNO3Plasma C140, 147AgNO3Plasma C140, 147AgNO3Plasma C141 andAgzeolitePlasma A186Plasma PPlasma A186Plasma PPlasma B96Plasma B96151Plasma CPlasma B86NiNickel wirePlasma A96CuCopper wirePlasma A188CuSO4Copper wirePlasma A188NiNickel wirePlasma A189 andCuSO4Copper wirePlasma A189 andCuSO4Copper wirePlasma A189 andCuSO4Copper wirePlasma A189 andCuSO5Zinc platePlasma A189 andCuSO4Zinc platePlasma B96SnTin rodPlasma B98 andPr-AuHprCl ₀ , NaAuCl ₄ Plasma B98 andSn-PcAllow wirePlasma B98 andN+CrAllow virePlasma B102N+CrAllow virePlasma B102N+CrAllow virePlasma B102N+CrAllow virePlasma B102N+CrAllow virePlasma B102N+CrAllow virePlasma B102N+CrAllow virePlasma B102N-CrAllow virePlasma B102N+CrAllow virePlasma B102N+CrAllow vire	Ag	-		
AgNO, AgNO, AgNO, AgNO, AgNO, Piasma A140, 40, 40, 40, 40, 40, 40, 40, 40, 40,				88 and 99
AgNO3Pasma A18° and AgzeolitePasma A187Pasma A187Pasma A187Pasma B96Pasma A187Pasma B86NiNiccle wirePasma B86NiNiccle wirePasma B88, 89, 9CuCopper wirePasma A188CuCuSO4Pasma A189NiNiccle wirePasma A86NiNiccle wirePasma A88NiNiccle wirePasma A86CuSO4CuSO4Pasma A86CuCuSO4Pasma A86CuCuC12Pasma A86CuCuC2Pasma A89CuCuSO4Pasma A86CuCuSO4Pasma A86ZnCuSO4Pasma A86ZnNin ObjetiPasma A86SnNin ObjetiPasma A187Pi-AuPasma A187192Ni-CuNi(NO4)2-GH2O4Pasma A192Ni-CuAg and PirodPasma A192Ni-CuAlloy wirePasma B102Ni-CuAlloy wirePasma A192Sn-AsAlloy wirePasma A192Sn-AsAlloy wirePasma A193CuCoblit acetate, KBH4Pasma A193CuCuper fairPasma A88, 59, 59CuCuper fairPasma A88, 59, 59<				140, 147 and 151
Ag-zeolitePlasma A186PtPlatnum wirePlasma A187PtPlasma A9696I-ptCLPlasma C151I-ptCLPlasma A86NiNickel wirePlasma A96CuCopper wirePlasma A88CuCl_Copper wirePlasma A189 andCuCl_CuCl_Plasma A88NiNickel wirePlasma A86NiCuCl_Plasma A88CuCuCl_Plasma A88NiNickel wirePlasma A89 andCuCuCl_Plasma A88NiNickel wirePlasma A88NiCuCl_Plasma A89 andCuCuCl_Plasma A89 andCuCl_AutoresPlasma A88ZnTin rodPlasma A86ZnMin QuiviresPlasma A191Ni-CrAlgo wirePlasma A192Ni-CrAlgo wirePlasma B102Ni-CrAlgo wirePlasma B102Ni-CrAlgo wirePlasma B102Sh-AgAlgo wirePlasma A193Co-BaCobal acetare, KBH4Plasma A194Cu-Soported on Tiop, nanotubeTion, anotube and Pt wiresPlasma A194Cu-Soported on Tiop, nanotube and Pt wiresPlasma A194Cu-Soported on Tiop, nanotube and Pt wiresPlasma A194Cu-Soported on T		AgNO		184 and 185
PtPiatinum wirePlasma APlasma APlasma APlasma BPlasma A96Plasma C151Plasma B86NiNickel wirePlasma B86CuCooppr wirePlasma A188CuCuSO1Plasma A18986NiNickel wirePlasma A8889CuCuSO1Plasma A8889CuCuSO1Plasma A8889CuCuSO2Plasma A8889CuCuSO2Plasma A8889CuCuC2Plasma A8889CuCuC2Plasma A8889CuCuC2Plasma A8889CuCuC3Plasma A8889ZnCuSO2Plasma A8889ZnCuC3Plasma A8889ZnPlasma A1848889ZnCuSO3Plasma A18488ZnCuC3Plasma A184184SnPlasma A184184184SnAlga wiresPlasma A192124Ni-CuAlga wirePlasma B124Ni-CuAlga wirePlasma B124Sn-AgAlga wirePlasma A192Sinless tellAlga wirePlasma A194YaLQAAlga wirePlasma A194YaLQAAlga wirePlasma A194<		- · ·		
PlasmaPlasmaPlasmaPlasmaNiPlasmaPlasmaRefNiPlasmaPlasmaRefNiCallPlasmaRefCuCuClCuClPlasmaRefCuClCuClPlasmaRefRefCuClCuClPlasmaRefRefCuClCuClPlasmaRefRefCuClCuClPlasmaRefRefNiCuClPlasmaRefRefCuClCuClPlasmaRefRefCuClCuClPlasmaRefRefCuClCuClPlasmaRefRefCuClCuClPlasmaRefRefZnZinc platePlasmaRefRefSnTin rodPlasmaRefRefSnMinorPlasmaRefRefNi-CuAlloy wirePlasmaRefRefNi-CuAlloy wirePlasmaRefRefSn-PbAlloy wirePlasmaRefRefCu2Cobalt acetace, KBH_4PlasmaRefRefTA_JO_5Minium rodPlasmaRefRefTotauTinuim rodPlasmaRefRefTotauTinuim rodPlasmaRefRefCu2Coper foltPlasmaRefRefCu2Coper foltPlasmaRefRefCu2Coper foltPlasmaRefRef <t< td=""><td rowspan="4">Pt</td><td>8</td><td></td><td></td></t<>	Pt	8		
NiHaPCIdaPlasma C151NiNickel wirePlasma B86CuOpper wirePlasma B88, 89, 9CuCuCl2Plasma A189 andCuCl2Plasma A189 and86NiNickel wirePlasma A96CuCl2Plasma A189 and96CuCl2Plasma A88, 89, 996CuCl2Plasma A189 and189 andCuCl2Plasma A189 and189 andCuCl2Plasma A189 and189 andCuCl2Plasma A189 and189 andCuCl2Plasma A189 and144SnCuCl2Plasma A189 andPr-AuZinc platePlasma A180 andSnCucl2Plasma A191SnMaximesPlasma A191Sn-ApAg and Pt rodPlasma A191Ni-CuAlgo wirePlasma B102Ni-CuAlloy wirePlasma A192Sainless steelAlloy wirePlasma A193MoS2Oudar acetate, KBH,Plasma A194YAJO,Aluminum rodPlasma B196TiO2Ti wirePlasma B196TiO2Ti wirePlasma B196TiO2Ti wirePlasma B196TiO2Copper foilPlasma B196TiO2Copper foilPlasma B196Piellerene (Cop)Copper foilPlasma B196 <td></td> <td></td> <td></td>				
H2PCI6Plasma P86Nickel wirePlasma A96CuCopper wirePlasma A188CuCl2CuCl2Plasma A189CuS04Plasma A8686NiCuS04Plasma A86NiCuS04Plasma A96CuCuS04Plasma A96CuCl2Plasma A189CuCuCl2Plasma A189CuCuCl2Plasma A189CuS04Plasma A18986ZnCuCl2Plasma B86ZnCuS04Plasma B86ZnTin rodPlasma A191Pr-AuHad AuviresPlasma A191Pr-AuAga Pt rodPlasma B102Ni-CrAlloy wirePlasma B102Ni-CrAlloy wirePlasma B102Sn-AgAlloy wirePlasma A193Sn-AgAlloy wirePlasma A193Sn-AgAlloy wirePlasma A194Sn-AgAlloy wirePlasma A194Sn-AgCobalt acetate, KBH4Plasma A194Sn-AgTitnium rodPlasma A194Sn-AgCobalt acetate, SBH4Plasma A194Sn-AgCobalt acetate, SBH4Plasma A194CoCCoper foilPlasma A194CoCCoper foilPlasma A194CoCCoper foilPlasma B194Culluose-ZnO comp				
NiNickel wirePlasma B96Plasma A88, 89, 9969188, 89, 996CuCopper wirePlasma A189 and189 and86NiUiCl2Plasma A969186NiNickel wirePlasma A969188CuCopper wirePlasma A189 and189 and86CuCopper wirePlasma A189 and18886CuCopper wirePlasma A189 and189 and184CuCuCopper wirePlasma B96 and144SnCuSO4Plasma B96 and157Pr-AuPlasma A191157157Pr-AuHgPrCl6, NaAuCl4Plasma B96 and102Ni-CrAlloy wirePlasma B102102Ni-CrAlloy wirePlasma A191102Sn-AgAlloy wirePlasma B102102Sn-AgAlloy wirePlasma A193193MoS2MoS2MoS2MoS2Plasma A195TiO2Tianium rodPlasma A195195TiA0CopPer foilPlasma B196195Cu20Copper foilPlasma B196196Cu20Copper foilPlasma B202196Cu20Copper foilPlasma B203196Cu20Copper foilPlasma B203196Cu20Copper foilP		H D+C		
CuPlasma AS8, 89, 9CuCopper wirePlasma A189 andCuCl2CuS0,Plasma A189 andNiWicel wirePlasma A86NiCuCl2Plasma A96CuCopper wirePlasma A188CuCuCl2Plasma A189 andCuCuCl2Plasma A189 andCuCuCl2Plasma B86ZnTin rodPlasma B86ZnTin rodPlasma B86ZnAu wiresPlasma A157Pr-AuHag PdCl6, NAuCl4Plasma B86Ag-PtAg and Pt rodPlasma A191Ni-CrAlloy wirePlasma A192Sn-AgAlloy wirePlasma A192Sn-AgAlloy wirePlasma B102 andSn-AgAlloy wirePlasma A193Sn-AgAlloy wirePlasma A193Sn-AgAlloy wirePlasma A193Sn-AgAlloy wirePlasma A193MoS2MoS2 powderPlasma A194Y-Al_O3Tinnium rodPlasma A194Y-Al_O3Tinnium rodPlasma B196TioTanium rodPlasma A193CuClaCopper follPlasma A196TioTinnium rodPlasma B196TioTinnium rodPlasma A196TioTinnium rodPlasma A196TioTinnium ro	Ni			
CuCopper wire CuCl2 CuCl2 CuCl2 CuCl2 CuCl2 CuCl2 NiPlasma A Plasma A189 and 189 and CuCl2 Copper wire CuCl2 CuC	111	Nickel wife		
CuCl2 CuSO4Plasma A189 and CuSO4NiCuSO4Plasma B86NiNickel wirePlasma B86CuCopper wirePlasma A188CuCl2CuSO4Plasma A189CuSO4Plasma A18986ZnCuSO4Plasma B86ZnZine platePlasma B86SnTin rodPlasma A157Pr-AuPt and Au wiresPlasma A157Pr-AuHpCIq, NAuCl4Plasma B86Ag-PtAg and Pt rodPlasma B102Ni-CrAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma A193MoS2Alloy wirePlasma A193MoS2Alloy wirePlasma A194Y-Al,O3Aluminum rodPlasma A195TiO2Ti wirePlasma B106TiO2Ti wirePlasma B109Defective black TiO2Ti wirePlasma B198Plasma B109Plasma B109CuCoCopper foilPlasma B198Plasma B109Plasma B109CuCoCopper foilPlasma B109CuCoCopper foilPlasma B201CuCoCopper foilPlasma B201CuQ0				88, 89, 96 and 106
NiCuSO,Plasma B86NiNickle wirePlasma A96CuCopper wirePlasma A188CuCl ₂ Plasma A189 andCuSO,Plasma A189 andZu CuSO,Plasma A189 andZu CuSO,Plasma B86ZnZine platePlasma B86SnTin rodPlasma B98 and 1Pr-AuPr and Au wiresPlasma B86Ag-PtAg and Pt rodPlasma A191Ni-CrAlloy wirePlasma B102Ni-CrAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Stainless steelAlloy wirePlasma A193Go-BCobalt acetate, KBH ₄ Plasma A194γ-Al ₂ O ₃ Aluminum rodPlasma B102TiO ₂ Tianium rodPlasma B196PiA ₂ OTianium rodPlasma B196PiATianium rodPlasma B196Cullose-ZnO compositeTio, nanotube and Pt wiresPlasma B196CuQCopper follPlasma B192CuGCopper follPlasma B201CuQCopper follPlasma B202CuQCopper follPlasma B201CuQCopper follPlasma B202CuQCopper follPlasma B2				
Nickel wirePlasma A96 Plasma BCuCopper wirePlasma A189 andCuCl2Plasma A189 andCuS0,Plasma A189 andCuS0,Plasma B86ZnCuS0,Plasma B96SnTin rodPlasma B98 and 1Pt-AuPt and Au wiresPlasma A157Pt-AuH2 ard Au wiresPlasma A157Pt-AuAg and Pt rodPlasma A191Ni-CrAlloy wirePlasma B102Ni-CrAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Stainless steelAlloy wirePlasma A193MoS2Aluminum rodPlasma A194YAJQ3Aluminum rodPlasma B196TiO2Ti wirePlasma B196TiO2Ti wirePlasma B196Plasma B102103198Pt anoparticles supported on TiO2 nanotubeTiO2 nanotube and Pr vitresPlasma B201CuOCopper foilPlasma B201CuOCopper platePlasma B202CuOCopper platePlasma B203CuJOGraphite in toluenePlasma B203CuJOCarbon-metl nanocompositesPlasma M204CuPo-retor		-		
CuPlasma A88, 89, 9CuCopper wirePlasma A189CuCl2Plasma A189 and189 andCuCl2CuSO4Plasma B86ZnZinc platePlasma C144SnTin rodPlasma B98 and 1Pt-AuPt and Au wiresPlasma A157Pt-AuAg and Pt rodPlasma A191Ni-CrAlloy wirePlasma A192Ni-CrAlloy wirePlasma B102Ni-CrAlloy wirePlasma B102Sn-AgAlloy wirePlasma A193Sn-AgAlloy wirePlasma A192StainEss steelAlloy wirePlasma A102Co-BAlloy wirePlasma A193MoS2Obalt acctate, KBH4Plasma A194γ-AlQ3Aluminum rodPlasma A195TiO2Titanium rodPlasma A196TiO3Titanium rodPlasma B109Pefective black TiO2Ti wirePlasma B109Pefective black TiO2Ti wirePlasma B109CuDOCopper foilPlasma B201Cu3OCopper platePlasma B202Cu4OCopper platePlasma B203Cu5OGraphite in toluenePlasma A203Cu5OGraphite in toluenePlasma A203Cu5OGraphite in toluenePlasma A203Cu5OGraphite in toluenePlasma A20		•		
CuCopper wire CuCl2Plasma A189 cuCl2CuCl2Plasma A189 cuCl2Plasma A189 cuCl2Zinc platePlasma B86ZnZinc platePlasma C144SnTin rodPlasma B98 and 1Pt-AuPt and Au wiresPlasma A157Pt-AuH_2PtCl6, NAuCl4Plasma A191Ni-CrAlloy wiresPlasma A191Ni-CrAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Stainless stelAlloy wirePlasma B102Co-BCobalt acetate, KBH4Plasma A193MoS2MoS2 powderPlasma A194TiO2Ti wirePlasma B196TiO2Ti wirePlasma B196TiO2Ti wirePlasma B196Colose-ZnO compositeTiO2, anotube and Pt wiresPlasma B199Celluces-ZnO compositeCopper foilPlasma B201Cu2OCopper foilPlasma B202Cu3OCopper platePlasma B203Fulleren (C_{oo})Carbon rodsPlasma B203Cu4OCopper platePlasma B204Cu5OCopper platePlasma A204Cu4OCopper platePlasma B203Cu4OCopper platePlasma B204 <t< td=""><td rowspan="4"></td><td>Nickel wire</td><td></td><td></td></t<>		Nickel wire		
CuCl2Plasma A189 and CuSO4CuSO4Plasma B86ZnZinc platePlasma C144SnTin rodPlasma B98 and 1Pt-AuPt and Au wiresPlasma A157Pt-AuH2PtCl6, NAAUCl4Plasma A191Ni-CuMg and Pt rodPlasma A191Ni-CrAlloy wirePlasma A192Ni-CuNi(NO3)2·6H2O, Cu(NO3)2·4H2OPlasma A192Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Stainless steelAlloy wirePlasma A193MoS2MoS2 powderPlasma A193YrAl2O3Aluminum rodPlasma A194YrAl2O3Tinum rodPlasma A195TiO2Ti wirePlasma B109Defective black TiO2Ti wirePlasma B196Pt nanoparticles supported on TiO2 nanotubeTiO2 nanotube and Pt wiresPlasma B199Cellulose-ZnO compositeCopper foilPlasma B200Cu2OCopper foilPlasma B201Cu2OCopper foilPlasma B203Fullerene (C ₆₀)Grabite in toluenePlasma A203Fullerene (C ₆₀)Grabite in toluenePlasma A203Cu3Don nanotubes (CNT)Carbon rodsPlasma A204Carbon-metal nanocompositesPlatinum aluminium, nickel,Plasma A205				88, 89, 96 and 106
CuSO4Plasma B86ZnZinc platePlasma C144ZnTin rodPlasma C144SnTin rodPlasma B98 and 1Pt-AuPt and Au wiresPlasma A157Pt-AuH_2PtCl6, NAuCl4Plasma B86Ag-PtAg and Pt rodPlasma A101Ni-CrAlloy wirePlasma A102Ni-CuAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Stainless steelAlloy wirePlasma A102Co-BCobalt acetate, KBH4Plasma A193MoS2MoS2 powderPlasma A194TiO2Tianium rodPlasma A195TiO2Tianium rodPlasma A196TiO2Ti wirePlasma A196Plasma B109109109Defective black TiO2Ti wirePlasma B109Celluose-ZnO compositeTiO2 nanotube and Pt wiresPlasma B196Cu2OCopper foilPlasma B201Cu2OCopper foilPlasma B203Fulleren (C ₆₀)Grabnite in toluenePlasma A203Fulleren (C ₆₀)Grabnite in toluenePlasma A203Cu3Don nanotubes (CNT)Carbon rodsPlasma A204Carbon-metal nanocompositesPlatinum, aluminium, nickel,Plasma B20			Plasma A	188
ZnZinc platePlasma C144SnTin rodPlasma B98 and 1Pt-AuTin rodPlasma B98 and 1Pt-AuHaptCl6, NAAuCl4Plasma B86Ag-PtAg and Pt rodPlasma B102Ni-CrAlloy wirePlasma B102Sn-AgAlloy wirePlasma B114Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Stainless steelAlloy wirePlasma A103Co-BCobalt acetate, KBH4Plasma A193MoS2Oxdat acetate, KBH4Plasma A194γ-Al2O3Aluminum rodPlasma A196TiO2Titn urr odPlasma A88, 95 atPt anoparticles supported on TiO2 nanotubeTiO2 nanotube and Pt wiresPlasma B198Pt nanoparticles supported on TiO2 nanotubeTiO2 nanotube and Pt wiresPlasma B198Pt nanoparticles supported on TiO2 nanotubeCopper foilPlasma B201CuQ-CCopper foilPlasma B201202Cu2OCopper foilPlasma B202Cu2OCopper foilPlasma B202In(OH) ₃ nanocubesIndiu and tin platePlasma A203Fulleren (C ₆₀)Grabit noluenePlasma A204Cu7On nanotubes (CNT)Carbon rodsPlasma A205<		CuCl ₂	Plasma A	189 and 190
SnTin rodPlasma B98 and 1Pt-AuPt and Au wiresPlasma A157Pt-AuH_2PtCl6, NAAUCl4Plasma A157Pt-AuH_2PtCl6, NAAUCl4Plasma B86Ag=PtAg and Pt rodPlasma A191Ni-CrAlloy wirePlasma A192Ni-CrAlloy wirePlasma B102Ni-CuNi(NO_3)_2·6H_2O, Cu(NO_3)_2·4H_2OPlasma A192Sn-AgAlloy wirePlasma B102Sn-AgAlloy wirePlasma B102Stainless steelAlloy wirePlasma A193Co-BCobalt acetate, KBH4Plasma A193MoS2MoS2 powderPlasma A194 γ -Al_2O_3Aluminum rodPlasma A195TiO2Titanium rodPlasma A88, 95 arPnuminum platePlasma B109Defective black TiO2Ti wirePlasma B199Cellulose-ZnO compositeZn($_{02}CCH_{3})_{2}$ ·2H_2OPlasma A200CuOCopper foilPlasma B201CuJ_OCopper platePlasma B202In(OH)_3 nanocubesIndjum and tin platePlasma B203Fullene (C ₆₀)Graphite in toluenePlasma A204Carbon nanotubes (CNT)Carbon rodsPlasma A204Carbon nanotubes (CNT)Carbon rodsPlasma A205-209Corbor rodsPlasma A205-209205-209Carbon nanotubes (CNT)Carbon r		$CuSO_4$	Plasma B	86
Pt-AuPt and Au wiresPlasma A157Pt-AuH ₂ PtCl ₀ , NAuCl ₄ Plasma B86Ag-PtAg and Pt rodPlasma B101Ni-CrAlgo wirePlasma B102Ni-CuNi(NO ₃) ₂ ·6H ₂ O, Cu(NO ₃) ₂ ·4H ₂ OPlasma A192Sn-AgAlloy wirePlasma B102Stainless steelAlloy wirePlasma B102 andCo-BCobalt acetate, KBH ₄ Plasma A193MoS ₂ powderPlasma A194Y-Al ₂ O ₃ Aluminum rodPlasma A194Y-Al ₂ O ₃ Titanium rodPlasma A196TiO ₂ Titanium rodPlasma A196Pt nanoparticles supported on TiO ₂ nanotubeTiO ₂ nanotube and Pt wiresPlasma B109Pt nanoparticles supported on TiO ₂ nanotubTiO ₂ nanotube and Pt wiresPlasma B201Cu ₂ OCopper platePlasma B201201Cu ₂ OCopper platePlasma B201201Cu ₂ OCopper platePlasma B201201In(OH) ₃ nanocubesIndium and tin platePlasma B203Fulleren (C ₆₀)Graphite in toluenePlasma A204Carbon nanotubes (CNT)Carbon rodsPlasma A205CNT-supported Pt nanoparticlesPl4, PtCl ₆ , CNTPlasma A205Carbon -metal nanocompositesPl4, PtCl ₆ , CNTPlasma A205Curbon -metal nanocompositesPlatinum, aluminium, nickel,Plasma A205 <td>Zn</td> <td>Zinc plate</td> <td>Plasma C</td> <td>144</td>	Zn	Zinc plate	Plasma C	144
Pt-AuH2PtCl6, NAAUCl4Plasma B86Ag-PtAg and Pt rodPlasma A191Ni-CrAlloy wirePlasma B102Ni-CuNi(No,3)2·6H2O, Cu(NO_3)2·4H2OPlasma A192Sn-AgAlloy wirePlasma B102Sn-PbAlloy wirePlasma B102Stainless steelAlloy wirePlasma A193Co-BCobalt acetate, KBH4Plasma A193MoS2Ocolat acetate, KBH4Plasma A194Y-Al2O3Aluminum rodPlasma A194TiO2Titanium rodPlasma A196TiO2Ti wirePlasma B196Plesma FIng and Plasma B196TiO2Ti wirePlasma B196Collulose-ZnO compositeTiO2 nanotube and Pt wiresPlasma B198CuQOCopper foilPlasma B201Cu2OCopper foilPlasma B202In(OH)3 nanocubes (CNT)Graphite in toluenePlasma A204Cu1OGraphite in toluenePlasma A204Carbon rondsCarbon rodsPlasma A204Cu2oTo rempositeFighite in toluenePlasma A204Cu2oTo remositesPlasma A204204Cu2oTo remositesFighite in toluenePlasma A204Cu2oTo remositesFighite in toluenePlasma A204Cu2oTo remositesFighite in toluenePlasma A204Cu2oTo remositesFighite in tolueneP	Sn	Tin rod	Plasma B	98 and 101
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Fullerene (C_{60})Graphite in toluenePlasma A204Carbon nanotubes (CNT)Carbon rodsPlasma A205-209CNT-supported Pt nanoparticlesPt, H_2PtCl_6, CNTPlasma A210Carbon-metal nanocompositesPlatinum, aluminium, nickel,Plasma B211	-		Plasma B	202
Carbon nanotubes (CNT)Carbon rodsPlasma A205-209CNT-supported Pt nanoparticlesPt, H2PtCl6, CNTPlasma A210Carbon-metal nanocompositesPlatinum, aluminium, nickel,Plasma B211				203
CNT-supported Pt nanoparticlesPt, H2PtCl6, CNTPlasma A210Carbon-metal nanocompositesPlatinum, aluminium, nickel,Plasma B211	Fullerene (C ₆₀)	Graphite in toluene	Plasma A	204
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Carbon-metal nanocomposites Platinum, aluminium, nickel, Plasma B 211		Pt, H_2 PtCl ₆ , CNT	Plasma A	210
			Plasma B	
	1	copper, tungsten, carbon electrodes		
	Ag on mesoporous silica		Plasma A	212 and 213

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synthesis of nanoparticles in water has also been described.¹⁶¹ Stable gold bimetallic nanoparticles of 5 to 20 nm can be synthesized using this method. On the other hand, in the case of microwave-generated in-liquid plasma (2.45 GHz), Toyota and coworkers¹⁶² succeeded in depositing diamond particles (7 to 8 μ m) onto silicon wafers to produce a diamond electrode in methanolic media. Syntheses of Cu, Au, and Pt nanoparticles by the in-liquid plasma reduction method have also been described.¹⁵¹

In fact, syntheses of nanomaterials have been reported extensively as there are many advantages in using the energy from in-liquid plasma to drive a chemical reaction. Thus, various nanoparticles of noble metals, alloys and metal-oxide nano-materials have been synthesized using various types of plasma-related techniques. Some of the nanoparticles, starting materials and type of in-liquid plasma used are summarized in Table 1.

Panomsuwan and co-workers¹⁶³ reported that metal-free Ndoped carbon nanoparticles (NCNPs) could be synthesized via a solution plasma process with the potential to achieve uniformly distributed nitrogen atoms. Accordingly, they used a set of cyanoaromatic molecules that included benzonitrile, 2cyanopyridine and cyanopyrazine as a single-source precursor in the synthesis without the addition of a metal catalyst. The resulting NCNPs revealed uniformly nanosized particles (20-40 nm) and an interconnected hierarchical pore structure with a high specific surface area (210–250 m² g⁻¹). The difference in carbon/nitrogen mol ratios of organic precursors gave rise to the variation of nitrogen-doping level in NCNPs from 0.63 to 1.94 atom%. A detailed electrochemical evaluation toward the oxygen reduction reaction (ORR) demonstrated that NCNPs exhibit a significant improvement in terms of both onset potential and current density under alkaline and acidic conditions. The predominant distribution of graphitic-N and pyridinic-N sites on NCNPs played an essential role in enhancing the ORR activity and the selectivity toward a fourelectron reduction pathway. More importantly, NCNPs possessed excellent robust long-term durability and strong methanol tolerance compared with those of a commercial Pt/ carbon catalyst. The possible formation mechanism of NCNPs is illustrated schematically in Fig. 16. After discharging for 30 min, black solid particles were separated from the liquid precursor by pouring through a filter paper and washed several times with ethanol until the wash solvent was colorless. The solution plasma approach used¹⁶³ should broaden and accelerate further research efforts on nitrogen-doped carbon catalysts, one-step closer to practical fuel cells and other related electrochemical devices.

Morishita and co-workers¹⁶⁴ investigated the routes of solution-plasma-induced nanocarbon formation from hexane, hexadecane, cyclohexane, and benzene; the synthesis from benzene was the most effective. However, the nanocarbons obtained from linear molecules were more crystalline than those from ring molecules. Linear molecules decomposed into shorter olefins, whereas ring molecules were reconstructed in the plasma. C–H dissociation proceeded in the saturated ring molecules, followed by conversion into unsaturated ring

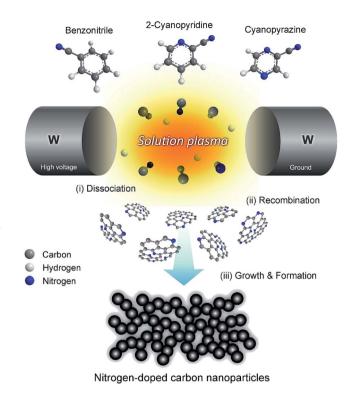


Fig. 16 Schematic illustration of the formation mechanism of nitrogen-doped carbon nanoparticles (NCNPs) *via* a solution plasma process. Modified with permission from ref. 163. Copyright 2016 by Elsevier.

molecules. However, unsaturated ring molecules were directly polymerized through cation radicals (*e.g.*, benzene radical cation) and were converted into two- and three-ring molecules at the plasma–solution interface. The nanocarbons from linear molecules were synthesized in plasma from small C2 molecules under heat; the products so-obtained were the same as those obtained *via* a pyrolysis synthesis. Conversely, the nanocarbons obtained from ring molecules were directly synthesized through an intermediate (such as benzene radical cations) at the

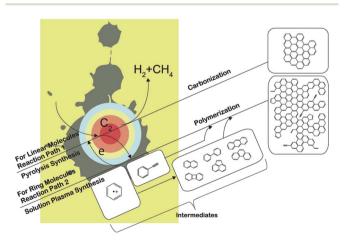


Fig. 17 Reaction routes from hexane, hexadecane, cyclohexane, and benzene. Modified with permission from ref. 164. Copyright 2016 by the Nature Publishing Group.

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interface between the plasma and the solution, resulting in the same products as those obtained *via* polymerization. These two different reaction fields provide a reasonable explanation for the fastest synthesis rate observed in the case of benzene. Two reaction paths from monomer to polycyclic aromatic hydro-carbons (PAHs), including graphene, are displayed in Fig. 17. One reaction path (reaction path 1) is from the plasma center. The solution is vaporized by a strong electric field between the electrodes. The vaporized solution forms a gas phase between the electrodes, which is converted into plasma after breakdown. In the plasma, organic compounds were almost completely decomposed, and were similar to the products obtained *via* a pyrolysis synthesis.

3.1.2 Quantum dots. Quantum dots are tiny particles or nanocrystals of a semiconducting material with diameters in the range of 2–10 nanometers (consisting of *ca.* 10–50 atoms), first discovered in 1980 by Ekimov and Onushchenko.²¹⁴ Quantum dots display unique electronic properties that are intermediate between those of bulk semiconductors and discrete molecules, and are partly the result of unusually high surface-to-volume ratios.²¹⁵

The most apparent result of this is the distinctive colors produced owing to different sizes of the nanocrystalline particles. Because of their small size, electrons in quantum dots are confined in small space (a quantum box). When the radii of the semiconductor nanocrystals are smaller than the exciton Bohr radius (exciton Bohr radius is the average distance between the electron in the conduction band and the hole it leaves behind in the valence band), the energy levels are quantized as per Pauli's exclusion principle. Because of the high level of control possible over the size of the nanocrystals produced, quantum dots can be tuned during the manufacturing process to emit light of various colors.²¹⁶ These unique properties render quantum dots versatile in such applications as transistors, solar cells, LEDs, diode lasers, as well as in medical imaging and in quantum computing.²¹⁷

Ultra-small sized (within 5 nm) and monodispersed silicon quantum dots (Si QDs) are ideal candidates for Si/C nanocomposites to be used as anode materials in lithium ion batteries. However, fabrication of these Si QDs/C nanocomposites remains a gigantic challenge in materials chemistry because of the small size, high chemical activity, and low density of Si QDs with Si-H terminated surfaces. Nonetheless, Wei and coworkers²¹⁸ reported a convenient synthetic method for the preparation of Si QDs/C nanocomposites by a novel liquid-phase plasma-assisted synthetic process, with the Si quantum dots embedded in a carbon matrix (Si-QDs/C) via a direct discharge between two electrodes powered by an AC power supply. Fig. 18a shows the setup for the liquid-phase plasma synthetic route.²¹⁸ Briefly, the copper and the tungsten (with a quartz shell) electrodes were placed into an ethanol solution containing Si QDs (photograph (i)). After a 20 min continuous sparking discharge, grey Si QDs/C composites were obtained successfully (photograph (ii)). Photograph (iii) shows the spark during the tungsten electrode discharging process. Fig. 18b displays the TEM image of the Si QDs, revealing a diameter within 5 nm and a single crystalline nature with

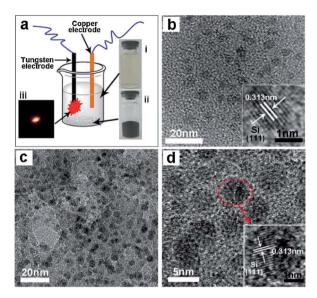


Fig. 18 (a) Setup scheme for the synthetic route. (b) TEM and HRTEM images of Si-quantum dots. (c) TEM image of the Si-quantum dots/C nano-composites. (d) HRTEM image of the Si quantum dots/C nano-composites. Reproduced from Wei *et al.*²¹⁸ Copyright 2013 by Elsevier.

a (111) spacing of about 0.313 nm in the Si crystal (see inset). Fig. 18c depicts the TEM image of the resulting Si QDs/C nanocomposites, and shows that the Si QDs are indeed embedded in large-sized amorphous carbon particles. The HRTEM image of the Si QDs/C nanocomposites is shown in Fig. 18d; the inset image highlights the Si QDs in the nanocomposites maintaining the good crystalline nature and confirms the lattice fringe space of *ca.* 0.313 nm of the (111) plane of the Si crystal. The Si-QDs/C nanocomposites demonstrated high specific capacity, good cycling life and high Coulombic efficiency as anode materials in lithium ion batteries.

3.2 Wastewater treatments

In-liquid plasma techniques in wastewater treatments are associated with the formation of a light emitting plasma around an electrode in a high conductivity electrolyte solution at moderate voltages up to 1 kV. In recent years, these techniques have attracted considerable interest as a tool for generating a large quantity of heat and a high yield of solvent-split radicals.219 There are several variations of using in-liquid plasma in the treatment of wastewaters: (A) immersing the electrodes in the waters (Fig. 19a), (B) using a water flow (Fig. 19b), and (C) using bubbles (Fig. 19c) that can be roughly divided into three groups.²²⁰ In method (A) - *i.e.*, in an underwater streamer discharge - to the extent that plasma is generated directly in the liquid, it is suitable for treating wastewaters by means of the resulting shock waves and the generated oxidative active species (e.g., 'OH radicals and ozone). Application studies have treated large quantities of water such as: ballast water, river waters, and dams from high concentrations to smaller scales.²²¹ On the other hand, in methods (B) and (C), since the gas is converted to plasma and is introduced into the liquid, the advantage here is that plasma can be generated easily while concurrently getting

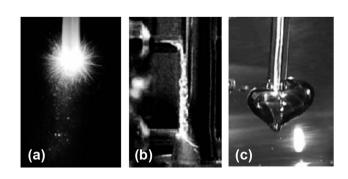


Fig. 19 Method of generating in-liquid plasma for use in water treatment: (a) method of the immersed electrodes in water; (b) method using water flow; (c) method using bubbles. Reproduced from Akiyama *et al.*²²⁰ Copyright 2014 by The Japan Society of Plasma Science and Nuclear Fusion Research.

significant energy saving. These systems generate plasma in bubbles and generate oxidized active species by diffusing them in water as compared with a system in which plasma is directly generated in an aqueous solution. However, compared with method (A), the number of generated 'OH radicals is reduced by about an order of magnitude,¹²⁷ so that the efficiency of the water treatment is lower. For instance, in the concurrent ultrasonic/microwave in-liquid plasma generator described in Fig. 10, the electrode is immersed in the aqueous solution, bubbles are then generated by the ultrasonic waves while plasma is generated in the solution so that the quantity of 'OH radicals generated is decreased. However, because of the cavitation effect of ultrasonic waves, the number of 'OH generated increases such that the total concentration of 'OH radicals produced is also increased.

Various oxidative active species are used in water treatments. Among these, the most powerful oxidative species are the 'OH radicals. Accordingly, studies have been carried out to increase the concentration of 'OH radicals and enhance diffusion efficiency in water in those water treatment processes that involve in-liquid plasma.²²² In addition, generation of 'OH radicals by in-liquid plasma in water and the decomposition of contaminants have also been undertaken.²²³ The mechanism of 'OH radical generation by in-liquid plasma is summarized by eqn (3)–(6). Electrons (e^{-*}) generated by the in-liquid plasma dissociate water and lead to the formation of 'OH radicals (eqn (3)). On the other hand, interaction of these electrons (e^{-*} ; eqn (4)) with dissolved oxygen generates oxygen atoms in their excited $O(^{1}D)$ and ground $O(^{3}P)$ states, which ultimately generate 'OH radicals from water (eqn (5) and (6)).²²³ Therefore, increasing the concentration of dissolved oxygen leads to an increase in the concentration of 'OH species. However, as the concentration of 'OH radicals increases, their subsequent recombination may be facilitated, so that it is disadvantageous to produce too many such species; note that the recombination process depends on the diffusion conditions of the 'OH radical species.

$$e^{-*} + H_2O \rightarrow e^- + OH + H$$
 (3)

$$e^{-*} + O_2 \rightarrow e^- + O(^1D) + O(^3P)$$
 (4)

$$O(^{1}D) + H_{2}O \rightarrow 2OH^{*}$$
(5)

$$O(^{3}P) + H_{2}O \rightarrow 2OH^{*}$$
(6)

3.2.1 Degradation of persistent organic pollutants (POPs). Among the many fluorinated organic compounds, perfluorooctanoic acid (PFOA: C₇F₁₅COOH) and perfluorooctanesulfonic acid (PFOS: C8F17SO3H) possess such excellent chemical and physical characteristics as water repellence, surface-active properties, heat resistance, and chemical resistance. Consequently, they have been used widely as industrial surfactants. However, from the viewpoint of environmental persistence, bioaccumulation and toxicity they are designated as regulated substances by the Stockholm convention (persistent organic pollutants (POPs) convention). Nonetheless, even though PFOS is an alternative albeit difficult surfactant in some industries, its use is exceptionally being permitted; treatment methods to dispose of PFOS have been investigated by Schroder and Maesters²²⁴ who noted that PFOA and PFOS are difficult to decompose with 'OH radicals and ozone. Successful methods to decompose these fluorinated substrates have involved: (i) photochemical decomposition using a photocatalyst,²²⁵ (ii) photolysis by 185 nm vacuum UV light,²²⁶ (iii) sulfuric acid radicals (SO₄^{-•}),²²⁷ (iv) a mechanochemical method,²²⁸ and (v) ultrasonic cavitation.²²⁹

Horikoshi *et al.*¹⁵⁶ achieved successful decomposition of perfluorooctanoic acid (PFOA) in ion-exchange water using inliquid plasma. The methodology involved concurrent ultrasonic/microwave irradiation in an in-liquid plasma type generator; results are reported in Fig. 20.

Plasma irradiation of PFOA (0.01 mM) in aqueous media for 90 s led to 59% defluorination accompanying the decomposition of PFOA, a substrate noted above as being difficult to decompose even with 'OH radicals. Nonetheless, PFOA was decomposed synergistically by the cavitation effect generated by

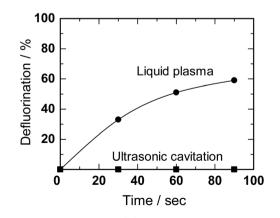
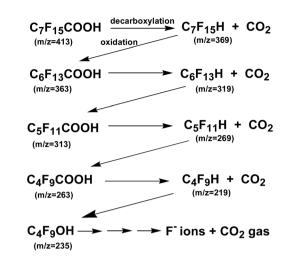


Fig. 20 Defluorination yields (%) from the degradation of aqueous PFOA solutions (0.01 mM) by ultrasonic cavitation alone and by the microwave discharge in-liquid plasma method under simultaneous ultrasonic cavitation (MW power, 220 W; power for cavitation, 90 W). Reproduced from Horikoshi *et al.*¹⁵⁶ Copyright 2017 by Elsevier.



Scheme 1 Sequential loss of CF₂ units from the PFOA perfluorinated acid and decarboxylated intermediates produced during the degradation of PFOA by plasma irradiation for 90 s. Note that loss of CF₂ units after the first decarboxylation step likely occurs by oxidation of the protonated terminal carbon and formation of F⁻ ions and CO₂ and so on in the Z-type pathway shown above. From Horikoshi and coworkers.¹⁵⁶ Copyright 2017 by Elsevier.

the homogenizer in addition to the local heat and shock waves generated by the in-liquid plasma. Monitoring the decomposition of PFOA by liquid chromatography/mass spectrometry (LC-MS) revealed a peak for PFOA at m/z = 413 that decreased in intensity (thus, decomposition of PFOA) and formation of intermediates whose peak intensities at m/z = 363, 313, 263 increased. Assigning these peaks to the various intermediates revealed that the decomposition of PFOA progressed through a gradual release of $-CF_2$ - units (Scheme 1). Complete mineralization of PFOA to CO_2 gas and F^- ions was achieved.¹⁵⁶

3.2.2 Sterilization of water by in-liquid plasma. Basic research on the sterilization of water with in-liquid plasma is being carried out quite proactively. The effects of in-liquid plasma are expected to be thermal effects in addition to those effects emanating from the generated oxidative active species ('OOH and 'OH radicals). As an example, the effect of culture temperature of Escherichia coli on pulsed electric field (PEF) sterilization has been studied by Ohshima and coworkers,²³⁰ who noted that the sterilization efficiency depends on the culture temperature of the E. coli bacteria and that the efficiency of PEF sterilization is influenced by the PEF treatment temperature. Moreover, insofar as the bactericidal effect of oxidative active species generated from plasmas in underwater streamer discharge liquids is concerned, sterilization is affected more by the stable hydrogen peroxide produced later in water than by the effect of 'OH species.231

3.2.3 Hybrid in-liquid plasma/photocatalytic degradation system. Several examples exist of wastewater treatments performed with in-liquid plasma in combination with other treatment methods. For instance, synergistic effects occur in wastewater treatments using ultrasonic cavitation of activated carbon^{232–236} in combination with a Fenton catalyst,^{237–243} with TiO₂ photocatalyst particles,^{244–247} and TiO₂ films.^{248,249} In

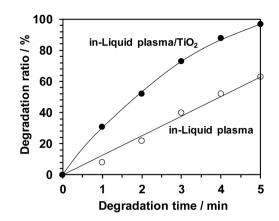


Fig. 21 Decomposition of methylene blue in aqueous solution by inliquid plasma alone and in combination with photocatalyst TiO_2 particles.¹⁷ Copyright 2017 by S. Horikoshi.

addition, decomposition of dyes (*e.g.*, methylene blue) can be achieved with an in-liquid plasma/photocatalyst system in which the TiO₂ photocatalyst ($\lambda < 387$ nm) was activated by the UV light emitted from the in-liquid plasma; no UV lamp was required.¹⁷ The extent of decomposition of methylene blue was 63% after a 5 min treatment by the in-liquid plasma alone; in the presence of TiO₂ particulates, the decomposition of methylene blue reached 97% (see Fig. 21). The concentration of dissolved oxygen was an important factor for enhancing process efficiency.¹⁷

3.2.4 Scaled-up process. The occurrence of Microcystis aeruginosa in nature, a species of freshwater cyanobacteria that can form harmful algal blooms, is cause of some serious concerns: e.g., deterioration of the landscape, emission of a putrid odor, oxygen deficiency in water ecosystems, and not least its toxic properties that greatly affect not only the natural environment but more so the fishing industry. Accordingly, techniques to remove such species by ultrasonic waves and by shock waves (and the like) are being examined. In this regard, Sakugawa and coworkers250 have treated Microcystis aeruginosa using in-liquid plasma; on-site demonstration experiments are also underway with a scaled-up apparatus. A demonstration experiment carried out in a vessel (width 3.9 m, height 1.6 m, weight 450 kg) floating in a dam (see Fig. 22) and equipped with a solar cell panel and magnetic pulse compression-type in-liquid plasma generator demonstrated the self-propelled removal of Microcystis aeruginosa by the generated in-liquid plasma.²⁵¹ The inliquid plasma caused the collapse of the gas bubbles inside the Microcystis aeruginosa cells triggering the buoyancy of the Microcystis aeruginosa to vanish; the treated blue patch sank into the water thus hindering the photosynthesis and suppressing any subsequent growth.

A large-sized apparatus that can process industrial wastewaters at low cost and re-use of the recycled water is being considered by the Mitsubishi Electric Co. Japan.²⁵² Unlike existing equipment, the particular equipment being considered features wastewater treatment that can be carried out with a simple method with no chemicals involved. As such, it is characterized by low cost and no concerns with regard to secondary pollution and use of the

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Fig. 22 Photograph of a self-propelled in-liquid plasma apparatus floating over a dam to destroy the harmful *Microcystis aeruginosa*. Reproduced from ref. 251. Copyright Kumamoto University, Japan.

recycled waters. This equipment is expected to become an integral part of a manufacturing process.

4. Summary remarks

This review article has outlined and described in-liquid plasma and has provided application examples of nanomaterials synthesis and wastewater treatment. Related to the present discussion, an earlier article by Kareem and Kaliani²⁵³ reviewed the glow discharge plasma electrolytic technique for nanoparticles synthesis, while Chen et al.254 provided a theoretical analysis of the nanomaterial synthetic process from a physics point of view, and most recently Rumbach and Go255 provided a perspectives article on plasmas. It is clear from the literature that compared to gas and solid plasmas the in-liquid plasma technique has yet to fully mature from a physical and engineering viewpoints. In addition, because it has yet to be fully developed exploitation of in-liquid plasma toward new chemical processes is highly desirable without being bound to some fixed concept of the past. Accordingly, in-liquid plasma is a field filled with many possibilities and consequently should trigger the discovery of innovative processes and products.

Conflicts of interest

Authors declare no conflicts of interest.

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